

LiBD-7 2015 – "Electrode materials"



Karlsruhe Institute of Technology

Microstructural and electrochemical comparison of as deposited and heat treated Li-Ni-Mn-Co-O thin film cathodes for Lithium-ion batteries

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Li-Ni-Mn-Co-O thin film cathodes have been deposited onto stainless steel substrates by a non-reactive r.f. magnetron sputtering process from a Lithium-rich Li_{1.11}(Ni_{0.37}Mn_{0.19}Co_{0.33})O_{1.77} target in a pure Argon atmosphere. The target power was 100 W and the deposition pressure 7 Pa. Coating thickness was about 1 µm. In order to induce a transition of the crystalline films from a disordered to an ordered layered structure the films were post heat treated between 300 °C and 700 °C for one hour at 10 mPa in Argon / Oxygen (80 : 20).

Film deposition

X-Ray diffraction **as deposited** **ICP-OES** and **CGHE** analysis (before annealing)







KIT – University of the State of Baden-Wuerttemberg and National Research Center of the Helmholtz Association

Acknowledgment:

The authors gratefully acknowledge the financial support by the Helmholtz-Portfolio-project "Elektrochemische Speicher im System - Zuverlässigkeit und Integration"

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